				l m ·
L Number	Hits	Search Text	DB	Time stamp
1	41	((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed	USPAT; US-PGPUB;	2004/08/13 15:34
		adj local adj oxidation adj of adj	EPO; JPO;	
		silicon)) and (oxide near2 (layer or film)	DERWENT;	
		near5 ((ion near2 implant\$4) near5 (oxygen	IBM TDB	
		near ion)))) not ((locos or (f adj locos)	120122	
		or (local adj oxidation adj of adj		
		silicon) or (framed adj local adj		
		oxidation adj of adj silicon)) same (oxide	İ	
		near2 (layer or film) near5 ((ion near2		
		implant\$4) near5 (oxygen near ion))))		
2	74	oxide near2 (layer or film)) same (((ion	USPAT;	2004/08/13 15:40
		near2 implant\$4) near5 (oxygen near ion))	US-PGPUB;	
		same (through near5 (oxide near2 (layer or	EPO; JPO;	
		film)))	DERWENT;	
			IBM_TDB	
-	7066	((438/42) or (438/225) or (438/297) or	USPAT;	2004/08/12 14:40
		(438/298) or (438/362) or (438/423) or	US-PGPUB;	
		(438/426) or (438/433) or (438/434) or	EPO; JPO;	
		(438/439) or (438/440) or (438/444) or (438/445) or (438/447) or (438/449) or	DERWENT; IBM TDB	
		(438/445) or (438/452) or (438/524) or	1207-120	
		(438/546) or (438/547) or (438/561) or		
		(438/766) or (438/769) or (438/770)).CCLS.		
-	486	<pre>implant\$4 near5 (oxygen near2 ion\$1)</pre>	USPAT;	2004/08/13 12:35
		near10 (silicon near2 (layer or film))	US-PGPUB;	
		-	EPO; JPO;	
			DERWENT;	
	1		IBM_TDB	
-	594	(soi or (silicon near2 insulator)) near5	USPAT;	2004/08/12 16:26
		(fully near2 deplet\$3)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	16040	logog on /f add logog\ on /logod ====	IBM_TDB	2004/00/12 12:27
-	16042	locos or (f adj locos) or (local adj	USPAT;	2004/08/13 12:37
		oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj	US-PGPUB; EPO; JPO;	
		silicon)	DERWENT;	
		,	IBM TDB	
-	2	(((implant\$4 near5 (oxygen near2 ion\$1)	USPAT;	2004/08/12 14:24
		near10 (silicon near2 (layer or film)))	US-PGPUB;	
	,	and ((soi or (silicon near2 insulator))	EPO; JPO;	
	J	near5 (fully near2 deplet\$3))) and (locos	DERWENT;	
]		or (f adj locos) or (local adj oxidation	IBM_TDB	
]		adj of adj silicon) or (framed adj local		
		adj oxidation adj of adj silicon))) and		
		(((438/42) or (438/225) or (438/297) or		
		(438/298) or (438/362) or (438/423) or		
		(438/426) or (438/433) or (438/434) or (438/439) or (438/440) or (438/444) or		
		(438/445) or (438/447) or (438/449) or		
		(438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/524) or		
		(438/546) or (438/547) or (438/561) or		
		(438/766) or (438/769) or		
		(438/770)).CCLS.)		
-	6	((implant\$4 near5 (oxygen near2 ion\$1)	USPAT;	2004/08/12 14:24
		near10 (silicon near2 (layer or film)))	US-PGPUB;	
		and ((soi or (silicon near2 insulator))	EPO; JPO;	
		near5 (fully near2 deplet\$3))) and (locos	DERWENT;	
		or (f adj locos) or (local adj oxidation	IBM_TDB	
		adj of adj silicon) or (framed adj local	_	
		adj oxidation adj of adj silicon))		
-	14	(implant\$4 near5 (oxygen near2 ion\$1)	USPAT;	2004/08/12 14:25
		<pre>near10 (silicon near2 (layer or film)))</pre>	US-PGPUB;	
		and ((soi or (silicon near2 insulator))	EPO; JPO;	
		<pre>near5 (fully near2 deplet\$3))</pre>	DERWENT;	
L			IBM TDB	<u> </u>

Climplants nears (layer or film) US-PGPUB; Same (trench\$2 or groove\$1 or open\$3 or hole) and (((438/42) or (438/225) or (438/237) or (438/238) or (438/352) or (438/434) or (438/426) or (438/440) or (438/441) or (438/440) or (438/450) or (438/571) or (438/524) or (438/561) or (438/561) or (438/570) or (438/570) or (438/700).CCLS.) USPAT; USPEPUB; same (trench\$2 or groove\$1 or open\$3 or hole) Same (trench\$2 or groove\$1 or open\$3 or hole) USPAT; USPAT U	14.20		I II CIDATE.	1 /: 1 + CA (
Same (trench\$2 or groove\$1 or open\$3 or hole) and (((438/42) or (438/225) or (438/297) or (438/298) or (438/362) or (438/433) or (438/433) or (438/433) or (438/444) or (438/433) or (438/444) or (438/444) or (438/444) or (438/445) or (438/447) or (438/444) or (438/445) or (438/447) or (438/524) or (438/561) or (438/56) or (438/547) or (438/561) or (438/56) or (438/579) or (438/769) or (438/769) or (438/770)).cCLS.) 47 implant\$4 near\$5 (oxygen near\$2 ion\$1) near\$10 (silicon near\$2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) USPAT; IBM TDB USPAT USPA		2004/08/12	USPAT;	(implant\$4 near5 (oxygen near2 ion\$1)	6
hole)) and (((438/42) or (438/25) or (438/297) or (438/298) or (438/362) or (438/433) or (438/423) or (438/426) or (438/443) or (438/433) or (438/444) or (438/445) or (438/447) or (438/447) or (438/449) or (438/445) or (438/447) or (438/524) or (438/526) or (438/526) or (438/566) or (438/567) or (438/570). CCLS.)					
(438/297) or (438/298) or (438/362) or (438/423) or (438/423) or (438/423) or (438/433) or (438/433) or (438/443) or (438/444) or (438/444) or (438/445) or (438/447) or (438/449) or (438/449) or (438/450) or (438/547) or (438/52) or (438/524) or (438/546) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS.) 47 implant\$4 near5 (oxygen near2 ion\$1)					
(438/423) or (438/426) or (438/433) or (438/434) or (438/434) or (438/440) or (438/444) or (438/444) or (438/447) or (438/444) or (438/445) or (438/452) or (438/546) or (438/547) or (438/561) or (438/566) or (438/567) or (438/561) or (438/566) or (438/567) or (438/70)).CCLS.) 47 implant\$\frac{4}{1} near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) 5 ("4292091" "4319954" "4323417" USPAT; IBM TDB USPAT 2004/08/12 "4338139" "4339285").PN. 20 4437225.URPN. USPAT 2004/08/12 "4810664" "5032535" "5114872" USPAT 2004/08/12 "5579978" "5481874" "5460983" "554229" "5512249" "5712173" "573813").PN. 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5723813").PN. 11 ("4437225" "548804" "5441094" "5707899" "5712186").PN. 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; USPA					
(438/434) or (438/439) or (438/440) or (438/441) or (438/444) or (438/447) or (438/447) or (438/449) or (438/445) or (438/447) or (438/541) or (438/540) or (438/547) or (438/561) or (438/561) or (438/766) or (438/769) or (438/761) or (438/761) or (438/770)).CCLS.) 47 implant\$\frac{4}{1}\$ near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) 5 ("4292091" "4319954" "4323417" USPAT USPAT USPAT USPAT; USPAT USPAT; USPAT USPAT; U			TBW_LDB		
(438/444) or (438/445) or (438/447) or (438/449) or (438/450) or (438/452) or (438/524) or (438/524) or (438/546) or (438/547) or (438/561) or (438/566) or (438/769) or (438/760)).CCLS.) 47 implant\$\frac{1}{4}\$ near5 (oxygen near2 ion\$\frac{1}{4}\$) near10 (silicon near2 (layer or film)) same (trench\$\frac{2}{2}\$ or groove\$\frac{1}{4}\$ or open\$\frac{3}{4}\$ or hole) 5 ("4292091" "4319954" "4323417" USPAT					
(438/449) or (438/450) or (438/452) or (438/524) or (438/524) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS.) implants4 near5 (oxygen near2 ion\$1)					
(438/524) or (438/546) or (438/547) or (438/561) or (438/766) or (438/769) or (438/770)).CCLS.) 47 implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) 5 ("4292091" "4319954" "4323417" USPĀT DĒRWENT; IBM_TDB USPĀT USPĀT USPĀT 2004/08/12 "4338139" "4339285").PN. 20 4437225.URPN. 6 ("4437225" "4683637" "4700454" USPĀT 2004/08/12 "5279978" "55114872" USPĀT 2004/08/12 "55279978" "55114872" USPĀT 2004/08/12 "55239978" "5510088" "5612239" "5612249" "5712173" "5733813").PN. 11 ("4437225" "4863878" "4948742" USPĀT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (Jelal adj oxidation adj of adj silicon) or (Jelal adj oxidation adj of					į l
(438/561) or (438/766) or (438/769) or (438/7701).CCLS.) implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) ("4292091" "4319954" "4323417" USPAT (IBM TDB USPAT) ("4338139" "4339285").PN. 4437225.URPN. 16 ("4437225" "4683637" "4700454" USPAT (IMB TDB USPAT) "5279978" "55123719" "5610088" "5612239" "5612249" "5712173" "5773813").PN. ("4437225" "4863878" "4948742" USPAT (IMB TDB USPAT) "518226" "5346841" "5441094" USPAT (IMB TDB USPAT) 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation					
47 implant\$4 near5 (oxygen near2 ion\$1)					
1					
near10 (silicon near2 (layer or film)) same (trench\$2 or groove\$1 or open\$3 or hole) US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT					
Same (trench\$2 or groove\$1 or open\$3 or hole)	14:29	2004/08/12	USPAT;	implant\$4 near5 (oxygen near2 ion\$1)	47
hole)			US-PGPUB;		
- 5 ("4292091" "4319954" "4323417" USPAT 2004/08/12 "4338139" "4339285").PN 20 4437225.URPN. USPAT 2004/08/12 "4810664" "5032535" "5114872" USPAT 2004/08/12 "5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "518226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (field near2 oxide) USPAT; 2004/08/12			EPO; JPO;	same (trench\$2 or groove\$1 or open\$3 or	
- 5 ("4292091" "4319954" "4323417" USPAT 2004/08/12 "4338139" "4339285").PN. - 20 4437225.URPN 16 ("4437225" "4683637" "4700454" USPAT 2004/08/12 "4810664" "5032535" "5114872" "5279978" "5418174" "5460983" "5612239" "5512249" "5712173" "5733813").PN 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (field near2 oxide) - 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12 1			DERWENT;	hole)	
"4338139" "4339285").PN. 4437225.URPN. ("4437225" "4683637" "4700454" USPAT US			IBM TDB		
- 20 4437225.URPN. "4683637" "4700454" USPAT 2004/08/12 "4810664" "5032535" "5114872" "5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN. 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) DERWENT; IBM_TDB USPAT; 2004/08/12	14:31	2004/08/12	USPĀT	("4292091" "4319954" "4323417"	5
- 20 4437225.URPN. "4683637" "4700454" USPAT 2004/08/12 "4810664" "5032535" "5114872" "5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN. 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) DERWENT; IBM_TDB USPAT; 2004/08/12				"4338139" "4339285").PN.	
- 16 ("4437225" "4683637" "4700454" USPAT 2004/08/12 "4810664" "5032535" "5114872" "5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "518226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) DERWENT; IBM_TDB (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12	14:32	2004/08/12	USPAT		20
"4810664" "5032535" "5114872" "5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN. 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12			USPAT	· ·	1 1
"5279978" "5418174" "5460983" "5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN. 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12				1 '	
"5482872" "5527719" "5610088" "5612239" "5612249" "5712173" "5733813").PN. ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; Silicon)or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12					
"5612239" "5612249" "5712173" "5733813").PN. ("4437225" "4863878" "4948742" "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12					
- 11 "5733813").PN. ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. - 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) - 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12					
- 11 ("4437225" "4863878" "4948742" USPAT 2004/08/12 "5182226" "5346841" "5441094" "5472902" "5488004" "5494846" "5707899" "5712186").PN. - 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) DERWENT; IBM_TDB USPAT; 2004/08/12 200				· · · · · · · · · · · · · · · · · · ·	
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"5472902" "5488004" "5494846" "5707899" "5712186").PN. fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (S-PGPUB; (framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12]
- 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (field near2 oxide) - 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12					
- 107731 fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (S-PGPUB; (framed adj local adj oxidation adj of adj EPO; JPO; silicon) or (field near2 oxide) - 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12				i ·	
adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj EPO; JPO; silicon) or (field near2 oxide) 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12	16.27	2004/08/12	יייבקסוו.	· ·	107731
(framed adj local adj oxidation adj of adj EPO; JPO; silicon)or (field near2 oxide) - 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12	10.27	2004/00/12			107731
silicon)or (field near2 oxide) DERWENT; IBM_TDB			1		
- 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12			1	cilianter (field near) exide	
- 11 (((438/42) or (438/225) or (438/297) or USPAT; 2004/08/12				Silicon/of (ffeld hearz oxide)	
	14.41	2004/00/12		///430/43\ om /430/33E\ om (430/307\ om	1 11
(430/230) OL (430/302) QL (430/423) OL USTEGROD;	14.41	2004/00/12	· ·		++
(438/426) or (438/433) or (438/434) or EPO; JPO;			1		
(438/439) or (438/440) or (438/444) or DERWENT;			1		
(438/445) or (438/447) or (438/449) or IBM_TDB			TRW_LOR		
(438/450) or (438/452) or (438/524) or					
(438/546) or (438/547) or (438/561) or					
(438/766) or (438/769) or					
(438/770)).CCLS.) and ((implant\$4 near5					
(oxygen near2 ion\$1) near10 (silicon near2					
(layer or film))) and (locos or (f adj					
locos) or (local adj oxidation adj of adj					1
silicon) or (framed adj local adj		1			
oxidation adj of adj silicon)))					
- 62 (implant\$4 near5 (oxygen near2 ion\$1) USPAT; 2004/08/12		2004/08/12	USPAT;	(implant\$4 near5 (oxygen near2 ion\$1)	62
near10 (silicon near2 (layer or film))) US-PGPUB;	14:54		US-PGPUB;		
and (locos or (f adj locos) or (local adj EPO; JPO;	14:54				1 1
oxidation adj of adj silicon) or /framed DERWENT.	14:54		EPO; JPO;	and (locos or (f adj locos) or (local adj	
Onidacton adj Of adj Stitcom/ Of (framed DERWENT,	14:54		EPO; JPO; DERWENT;	and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed	
adj local adj oxidation adj of adj IBM TDB	14:54		DERWENT;	oxidation adj of adj silicon) or (framed	

200.00	51	((implant\$4 near5 (oxygen near2 ion\$1)	USPAT;	2004/08/12	14:44,
		near10 (silicon near2 (layer or film)))	US-PGPUB;		
		and (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed	EPO; JPO; DERWENT;		
		adj local adj oxidation adj of adj	IBM TDB		
		silicon))) not ((((438/42) or (438/225) or	1517_155		
		(438/297) or (438/298) or (438/362) or]		
		(438/423) or (438/426) or (438/433) or			
		(438/434) or (438/439) or (438/440) or			
		(438/444) or (438/445) or (438/447) or			\
1		(438/449) or (438/450) or (438/452) or			
		(438/524) or (438/546) or (438/547) or			
	Ì	(438/561) or (438/766) or (438/769) or (438/770)).CCLS.) and ((implant\$4 near5			
		(oxygen near2 ion\$1) near10 (silicon near2			
		(layer or film))) and (locos or (f adj			
	İ	locos) or (local adj oxidation adj of adj			
		silicon) or (framed adj local adj			
		oxidation adj of adj silicon))))			
-	. 5	\=	USPAT;	2004/08/12	14:53
		near10 (silicon near2 (layer or film))) same (locos or (f adj locos) or (local adj	US-PGPUB; EPO; JPO;		
		oxidation adj of adj silicon) or (framed	DERWENT;		
		adj local adj oxidation adj of adj	IBM TDB		
		silicon))]	
-	12		USPAT;	2004/08/12	14:56
1		near10 (silicon near2 (layer or film)))	US-PGPUB;		
		same oxidiz\$5) and (locos or (f adj locos)	EPO; JPO;	<u> </u>	
	i	or (local adj oxidation adj of adj	DERWENT;		
		silicon) or (framed adj local adj oxidation adj of adj silicon))	IBM_TDB		
_	59		USPAT;	2004/08/12	14:56
		near10 (silicon near2 (layer or film)))	US-PGPUB;		
		same oxidiz\$5	EPO; JPO;		
		·	DERWENT;		
	106		IBM_TDB	0004/00/10	16.06
-	486	<pre>implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film))</pre>	USPAT; US-PGPUB;	2004/08/12	16:26
1		nearlo (Silicon nearz (layer of limm))	EPO; JPO;		
			DERWENT;		
			IBM_TDB		
-	594	(soi or (silicon near2 insulator)) near5	USPAT;	2004/08/12	16:27
1		(fully near2 deplet\$3)	US-PGPUB;		
			EPO; JPO;		
			DERWENT; IBM TDB		
_	107731	fox or locos or (f adj locos) or (local	USPAT;	2004/08/12	21:17
		adj oxidation adj of adj silicon) or	US-PGPUB;	3001,00,12	,
		(framed adj local adj oxidation adj of adj	EPO; JPO;	1	
		silicon)or (field near2 oxide)	DERWENT;		
	_	/implant64 nooms /courses accord decade	IBM_TDB	2004/00/10	16.50
-	0	(implant\$4 near5 (oxygen near2 ion\$1) near10 (silicon near2 (layer or film)))	USPAT; US-PGPUB;	2004/08/12	то:28
		same ((soi or (silicon near2 insulator))	EPO; JPO;		
		near5 (fully near2 deplet\$3))	DERWENT;		
			IBM_TDB		
-	14	(implant\$4 near5 (oxygen near2 ion\$1)	USPĀT;	2004/08/12	16:28
		<pre>near10 (silicon near2 (layer or film)))</pre>	US-PGPUB;		
		and ((soi or (silicon near2 insulator))	EPO; JPO;	1	
		near5 (fully near2 deplet\$3))	DERWENT; IBM TDB		
_	6	("5955767" "6100159" "6174754"	USPAT	2004/08/12	16:32
		"6403433" "6501133" "6515333").PN.		-5551, 55, 12	
-	0	6724049.URPN.	USPAT	2004/08/12	16:33
-	1	6501133.URPN.	USPAT	2004/08/12	
-	8	("5614729" "5920097" "5955767"	USPAT	2004/08/12	16:34
		"6100159" "6130457" "6174754"			
L		"6287901" "6303412").PN.	<u> </u>	L	

-	41	((soi or (silicon near2 insulator)) near5 (fully near2 deplet\$3)) same (fox or locos	USPAT; US-PGPUB;	2004/08/12 16:58
		or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide))	EPO; JPO; DERWENT; IBM_TDB	
-	107731	fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon) or (field near2 oxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/08/12 21:18
-	92	(fox or locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)or (field near2 oxide)) near10 (sidewall\$1 near trench\$2)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/08/12 21:45
_	18		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/08/12 21:46
_	995	<pre>oxide near2 (layer or film) same ((ion near2 implant\$4) near5 (oxygen near ion))</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/08/13 15:37
-	. 16042	locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)	USPĀT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/08/13 12:37
-	15	<pre>(oxide near2 (layer or film) same ((ion near2 implant\$4) near5 (oxygen near ion))) same (locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon))</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/13 12:37
-	325	,	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/13 15:36
i -	49	(locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/13 12:44
	8	(locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) same (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/13 12:44
-	41	((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj oxidation adj of adj silicon)) and (oxide near2 (layer or film)	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/08/13 15:33
	r	near5 ((ion near2 implant\$4) near5 (oxygen near ion)))) not ((locos or (f adj locos) or (local adj oxidation adj of adj silicon) or (framed adj local adj	IBM_TDB	
		oxidation adj of adj silicon)) same (oxide near2 (layer or film) near5 ((ion near2 implant\$4) near5 (oxygen near ion))))		

	276	(avide many (layor or film) moors (/ion	USPAT;	2004/08/13 12:52
-	276			2004/00/13 12.32
		near2 implant\$4) near5 (oxygen near ion)	US-PGPUB;	
)) not ((locos or (f adj locos) or (local	EPO; JPO;	
		adj oxidation adj of adj silicon) or	DERWENT;	
1		(framed adj local adj oxidation adj of adj	IBM_TDB	
	·	silicon)) and (oxide near2 (layer or film)	_	
		near5 ((ion near2 implant\$4) near5 (oxygen		
		near ion))))		
-	0	((oxide near2 (layer or film) near5 ((ion	USPAT;	2004/08/13 12:52
İ		near2 implant\$4) near5 (oxygen near ion)	US-PGPUB;	
)) not ((locos or (f adj locos) or (local	EPO; JPO;	
		adj oxidation adj of adj silicon) or	DERWENT;	
		(framed adj local adj oxidation adj of adj	IBM TDB	
ì		silicon)) and (oxide near2 (layer or film)		
		near5 ((ion near2 implant\$4) near5 (oxygen		
1		near ion))))) and (locos or (f adj locos)		
]				
		or (local adj oxidation adj of adj		
		silicon) or (framed adj local adj		
		oxidation adj of adj silicon))		